

# INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Multiple sheets used when necessary)

SHEET 1 OF 1

Application No.	10/564791
Filing Date	January 13, 2006
First Named Inventor	Takada et al.
Art Unit	1742
Examiner	Piery, Michael
Attorney Docket No.	SHIGA3.008APC

## U.S. PATENT DOCUMENTS

Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
/M.P./	1	5,373,026	12-1994	Bartz et al.	
/M.P./	2	2001/0000930A1	05-10-2001	Roland Y. Kim	

## FOREIGN PATENT DOCUMENTS

Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T <sup>1</sup>

## NON PATENT LITERATURE DOCUMENTS

Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>1</sup>
/M.P./	3	LIU et al., "Preparation and Characterization of Copolymers Containing (+)-Bornyl Methacrylate and Their Racemate for Positive-Tone Photoresist," <i>J. Appl. Polym. Sciences</i> , 81:3538-3544, (2001)	
/M.P./	4	FEDYNYSHYN, et al. "Contribution of Photoacid Generators To Material Roughness," <i>J. Vac. Sci. Technology</i> , B24(6), 3031-3039, (2006)	
/M.P./	5	ZHAROV, et al., "Mechanistic Studies of the Acidolysis Reactions Occurring in Silicon-Containing Bilayer Photoresists" <i>Chem. Mater</i> (14)656-63, (2002)	

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Examiner Signature	/Michael Piery/	Date Considered	10/09/2011
*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.			

T<sup>1</sup> - Place a check mark in this area when an English language Translation is attached.